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Enhancing the efficiency of slit-coupling to surface-plasmon-polaritons via dispersion engineering

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Abstract: We describe a simple method for enhancing the efficiency of coupling from a free-space transverse-magnetic (TM) plane-wave mode into a surface-plasmon-polariton (SPP) mode. The coupling structure consists a metal film with a dielectric-filled slit and a planar, dielectric layer on the slit-exit side of the metal film. By varying the dielectric layer thickness, the wavevector of the SPP mode on the metal surface can be tuned to match the wavevector magnitude of the modes emanating from the slit exit, enabling high-efficiency radiation coupling into the SPP mode at the slit exit. An optimal dielectric layer thickness $\approx 100\text{nm}$ yields a visible-frequency SPP coupling efficiency $\approx 4$ times greater than the SPP coupling efficiency without the dielectric layer. Commensurate coupling enhancement is observed spanning the regime $400\text{nm} \leq \lambda_0 \leq 700\text{nm}$. We map the dependence of the SPP coupling efficiency on the slit width, the dielectric-layer thickness, and the incident wavelength to fully characterize this SPP coupling methodology.

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References and links
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1. Introduction

Surface plasmon polaritons (SPPs) are bounded, transverse-magnetic (TM)-polarized electromagnetic modes that propagate along the interface between a dielectric and a metal and are confined to the interface by the exponential decay of the fields in the directions perpendicular to the interface. For frequencies above the near-infrared, the SPP wavelength can be significantly smaller than the wavelength of unbounded plane waves in the dielectric region. The field confinement and wavelength reduction achievable with SPPs hold promise to enabling dramatic miniaturization of the feature sizes of conventional optical devices [1–3] and optical sensors [4].

Due to the lack of widespread SPP sources, SPP devices typically incorporate a coupling structure to enable plane-wave modes to excite SPP modes [5]. Inefficiency associated with coupling from plane-wave modes into SPP modes remains a significant source of loss in SPP devices. Designing high-efficiency SPP coupling schemes remains an important objective in the efforts to enable real-world applications of SPPs [6].

Plane-wave illumination of a dielectric/metal interface does not enable coupling of plane-wave modes into SPP modes since the SPP wavevector does not intercept the plane-wave wavevector. Scatterers have been used to bridge the inherent wavevector mismatch between plane-wave and SPP modes. When a scatterer is illuminated, enhancement of the incident plane-wave wavevector by the Fourier components of the defect geometry enables wavevector matching between the incident light and the SPP mode. One of the most widely used techniques for SPP coupling is a single slit in a metal film [7–12]. A single slit is compact, amenable to integration, and insensitive to the incident angle of light. However, slit-coupling to SPP modes is inherently inefficient because a large fraction of the light incident on the slit is lost to radiation [8]. The motivation of this work is to devise a simple method to enhance the efficiency of SPP coupling at the exit of a slit via dispersion engineering, whereby the dielectric environment of the slit is modified to enable wavevector matching between the light emanating from the slit exit and the SPP mode on the adjacent metal surface.

2. Single-Slit SPP-Coupling Mechanism

Figure 1(a) depicts the geometry to be studied. A semi-infinite metal with relative permittivity \( \varepsilon_m \) is immersed in a dielectric medium with relative permittivity \( \varepsilon_d \). The film extends infinitely in the \( x \)- and \( y \)-directions and occupies the region \(-t < z < 0\). A slit of width \( w \) oriented parallel to the \( z \)-axis and centred at \( y = 0 \) is cut into the metal film. A transverse-magnetic (TM) polarized electromagnetic plane wave of wavelength \( \lambda_0 \) and wavevector \( \sqrt{\varepsilon_d} k_0 \), where \( k_0 = 2 \pi / \lambda_0 \) is the free-space wavevector, is normally incident onto the bottom surface of the film located at \( z = -t \). A fraction of the electromagnetic plane-wave mode incident onto the slit couples into a guided mode in the slit. Light exiting the slit in the region \( z > 0 \) consists of radiating and evanescent modes with wavevector magnitude \( k_i \simeq \sqrt{\varepsilon_d} k_0 \); coupling to the SPP mode on the metal surface is inefficient because \( k_i \) is less than the wavevector of the SPP mode on the metal.
The mode, $k_{SPP}$, given by

$$k_{SPP} = k_0 \left( \frac{\varepsilon_m \varepsilon_d}{\varepsilon_m + \varepsilon_d} \right)^{1/2}. \quad (1)$$

diffraction at the slit exit disperses the modes at the slit exit into a continuum of directions described by $\vec{k} = k_x \hat{x} + k_z \hat{z}$. Assuming that the field at the exit of the slit in the plane $z = 0$ has the form

$$E(x, 0) = \begin{cases} E_i & |x| < w/2 \\ 0 & |x| > w/2 \end{cases} \quad (2)$$

where $E_i$ is a constant, the amplitude distribution of the diffraction spectrum is given by

$$A(k_x) = \frac{E_i \sin(k_x w/2)}{\pi k_x}. \quad (3)$$

diffracted modes that assume a real wavevector $x$-component $k_x < k_i$ possess a real wavevector $z$-component

$$k_z = \left( k_i^2 - k_x^2 \right)^{1/2}, \quad (4)$$
corresponding to radiative modes that propagate away from the slit exit. On the other hand, diffracted modes that assume a real wavevector $x$-component $k_x > k_i$ possess an imaginary wavevector $z$-component

$$k_z = i \left( k_x^2 - k_i^2 \right)^{1/2}, \quad (5)$$
corresponding to evanescent modes confined to the slit region. A fraction of the evanescent modes with values of $k_z$ matching the wavevector of the SPP mode on the air-silver interface couple from the slit exit to the $\pm x$-directed SPP modes.
The total intensity radiated from the slit, \( I_r \), is obtained by a summation, weighted by the squared amplitude distribution of the diffraction spectrum, of the intensities of the radiated modes [14]

\[
I_r = \frac{4|E_i|^2}{\pi kw^2} \int_0^\infty \frac{k \sin^2(kw/2)}{k^2} dk
\]  

(6)

Likewise, the total intensity confined to the slit-exit plane, \( I_e \), is obtained by a summation of the intensities of the evanescent modes

\[
I_e = \frac{4|E_i|^2}{\pi kw^2} \int_{k_i}^\infty \frac{\sin^2(kw/2)}{k^2} e^{-2\sqrt{k^2-k_i^2}z} dk.
\]  

(7)

A fraction of \( I_e \) constitutes the SPP mode intensity \( I_{SPP} \) and the remainder constitutes the intensity of decaying modes \( I_d \). The observable coupling efficiency of the radiating light from the slit to the SPP mode on the metal surface can be expressed as

\[
\eta = \frac{I_{SPP}}{I_r + I_{SPP}},
\]  

(8)

which assumes a value in the range \( 0 \leq \eta \leq 1 \).

Fig. 2. Simulation geometry used to study SPP coupling from an illuminated slit. The detectors \( D_1 \) and \( D_2 \) capture the SPP modes, and the detector \( D_3 \) captures the radiating modes.

To enhance the SPP coupling efficiency from a slit, the configuration depicted in Figure 1(b) is proposed. A semi-infinite metal film with a slit of width \( w \) is immersed in free-space with permittivity \( \varepsilon_0 \). The slit in the film is completely filled with a lossless dielectric of relative permittivity \( \varepsilon_d \). A semi-infinite dielectric layer, also of relative permittivity \( \varepsilon_d \), is placed on the metal film such that it occupies the region \( 0 < z < d \). In the limits where \( d \to \infty \) and \( d \to 0 \), the SPP wavevector approaches

\[
k_{SPP} = k_0 \left( \frac{\varepsilon_m \varepsilon_d}{\varepsilon_m + \varepsilon_d} \right)^{1/2}
\]  

(9)

and

\[
k_{SPP} = k_0 \left( \frac{\varepsilon_m}{\varepsilon_m + 1} \right)^{1/2},
\]  

(10)

respectively. We assume that the magnitude of the wavevector of the radiating and evanescent modes at the slit exit in the region \( z > 0 \) is \( k_i \simeq \sqrt{\varepsilon_d}k_0 \); in reality, the light radiating from the
slit consists of a distribution of wavevector magnitudes, of which a large fraction corresponds to $\sqrt{\varepsilon_d k_0}$ [8,14]. By varying the thickness of the dielectric layer, $d$, the effective wavevector of the SPP mode can be tuned such that $k_{SPP} \approx k_z$, enabling efficient coupling of light from the slit into the SPP mode on the adjacent metal surface. The dielectric layer has an added practical benefit of passivation of the underlying metal surface; this is especially important for the case of silver, which tarnishes readily in the presence of atmospheric sulphur. To characterize this coupling scheme, we study the SPP-coupling efficiency as a function of the slit width ranging from 50nm to 300nm, the thickness of the dielectric layer ranging from 0nm to 700nm, and the wavelength ranging from 400nm to 700nm to determine a set of optimal parameters that yield maximum coupling. Judicious selection of the dielectric layer thickness and the slit width is shown to yield coupling efficiency $\eta \simeq 0.77$ extending over the visible wavelength range $400\text{nm} \leq \lambda_0 \leq 700\text{nm}$; the achieved efficiency is $\simeq$ 4 times more efficient than that observed for a slit without the dielectric layer. Design guidelines are established to assist the experimentalist in realizing coupling geometries that yield optimal SPP coupling.

3. Methodology

We select numerical solutions of Maxwell’s Equations via the finite-difference time-domain (FDTD) method to model the electromagnetic response of the isolated slit structure to quasi-plane-wave illumination conditions. The simulation grid has dimensions of $4000 \times 1400$ pixels with a resolution of 1nm/pixel and is surrounded by a perfectly-matched layer to eliminate reflections from the edges of the simulation space. The structure consists of a 300-nm-thick silver film with a slit of width $w$; the dielectric in the slit and the dielectric layer on the metal film consist of dispersion-less glass with refractive index $\sqrt{\varepsilon_d} = 1.5$. The permittivity of silver is modeled by fitting to experimental data [15]. The corners of the slit are chamfered with a chamfer radius of 3nm. This was done to eliminate perfectly sharp edges of the slit which can result in highly localized electric dipoles that affect the slit throughput [7]. The incident beam is centered in the simulation space at $x = 0$ and propagates in the $+z$-direction, with a full-width-at-half-maximum of 1200nm and a waist located at $z = 0$. The incident electromagnetic wave has a wavelength 500nm and is TM-polarized such that the magnetic field, $H_y$, is aligned along the y-direction.

The control variables are the incident polarization (TM), the metal type (silver), the dielectric type (dispersion-less glass), and the thickness of the metal layer ($t = 300\text{nm}$). The independent variables are the slit width $w$, which is varied from 50nm to 300nm in increments of 50nm, the dielectric layer thickness $d$, which is varied from 0nm to 700nm in increments of 50nm, and the free-space wavelength $\lambda_0$, which is varied over the visible frequency regime from 400nm to 700nm in increments of 100nm. The dependent variables are the intensity of the SPP modes coupled to the exit surface of the metal film, $I_{SPP}$, the intensity of the radiated modes leaving the slit region, $I$, and the SPP coupling efficiency, $\eta$.

The dependent variables are quantified by placing line detectors, $D_1$, $D_2$, and $D_3$, in the simulation space to integrate the instantaneous magnitude squared of the magnetic field crossing the plane of the detectors (Figure 2). The detectors, $D_1$, $D_2$, and $D_3$, capture different components of the intensity pattern radiated from the exit of the slit. The line detectors $D_1$ and $D_2$ straddle the metal/dielectric interface and are situated adjacent to the slit exit a length $L_1 = \lambda_0$ away from the edges of the slit. $D_1$ and $D_2$ have identical heights $H_1 = \lambda_0/4 + 50\text{nm}$, of which 50nm extends into the metal and $\lambda_0/4$ extends into the dielectric region above the metal. $D_1$ and $D_2$ capture the intensity of the left- and right-propagating SPP modes that are coupled from the slit and flow on the metal surface. The line detector $D_3$ is centered on the slit and extends over the dielectric region above the metal surface with a height of $H_2 = 3\lambda_0/4$ and a length of $L_2 = 2\lambda_0 + w$. $D_3$ captures the intensity of light radiated away from the slit that is not coupled.
to the surface of the metal.

Because the detectors indiscriminately capture the intensity crossing the detector plane, $I_r$ captured by $D_1$ and $D_2$ and $I_{SPP}$ captured by $D_3$ constitute sources of error. The fraction of $I_r$ captured by $D_1$ and $D_2$ is estimated by calculating the acceptance angle formed by the line detectors $D_1$ and $D_2$ with respect to the exit of the slit and integrating Eqn. 6 over this angle. At $\lambda_0 = 500\text{nm}$, < 3% of $I_r$ is captured by $D_1$ and $D_2$. The fraction of $I_{SPP}$ captured by $D_3$ is estimated from the attenuation of the SPP fields in the $z$-direction. At $\lambda_0 = 500\text{nm}$, < 8% of $I_{SPP}$ is captured by $D_3$.

The time-averaged intensities of the SPP mode and the radiated modes are quantified by

$$I_{SPP} = \left< \int_{D_1} |H_y|^2 d\ell + \int_{D_2} |H_y|^2 d\ell \right> \tag{11}$$

and

$$I_r = \left< \int_{D_3} |H_y|^2 d\ell \right> \tag{12}$$

where the angled brackets indicate time-averaging of the quantity within the brackets.

4. Control Studies

<table>
<thead>
<tr>
<th>Simulation Geometry</th>
<th>$\lambda_i$</th>
<th>$\lambda_{SPP}$</th>
<th>$\eta$</th>
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</thead>
<tbody>
<tr>
<td></td>
<td>500 nm</td>
<td>473 nm</td>
<td>20%</td>
</tr>
<tr>
<td></td>
<td>500 nm</td>
<td>473 nm</td>
<td>21%</td>
</tr>
<tr>
<td></td>
<td>333 nm</td>
<td>292 nm</td>
<td>25%</td>
</tr>
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</table>

Three control simulations are performed to establish baseline SPP-coupling-efficiency values. The control structures consists of a silver film of thickness $t = 300\text{nm}$ having a slit width of $w = 150\text{nm}$, where (1) the film is surrounded by free space and the slit is filled with free space, (2) the film is surrounded by free space and the slit is filled with glass, and (3) the film is surrounded by free-space and the slit is filled with glass. The slits are illuminated with a quasi-plane wave with a wavelength $\lambda_0 = 500\text{nm}$. Each geometry represents different situations in which the magnitude of the wavevector (or equivalently, wavelength) of the light radiating in the immediate vicinity of the slit exit is mismatched with the SPP wavevector (or wavelength) on the metal surface. The wavelength of the emanating light, $\lambda_i$, of the SPP mode, $\lambda_{SPP}$, are given in Table 1.
Fig. 3. Image of the FDTD-calculated instantaneous $|H_y|^2$ distribution for a slit of width $w = 150\text{nm}$ illuminated by a quasi-plane-wave of wavelength $\lambda_0 = 500\text{nm}$. The simulation geometry is depicted by the above graphic. Lines indicating the position of detectors $D_1$, $D_2$, and $D_3$ have been superimposed on the image.

Fig. 4. Principle of dispersion engineering to enhance slit-coupling to SPP modes. (a) Dispersion curve of $n_{SPP}$ as a function of $\lambda_0$ for various $d$ calculated from the roots of the eigenvalue equation for the SPP mode on an asymmetric, three-layer silver-glass-air waveguide. (b) $n_{SPP}$ as a function of $d$ for $\lambda_0 = 500\text{nm}$. The dotted gray line corresponds to the refractive index of a plane-wave mode in glass, $\sqrt{\varepsilon_d}$.

5. Results and Discussion

Shown in Fig. 3 is a snap-shot of the instantaneous $|H_y|^2$ distribution for illumination of the silver film immersed in free space. The slit sustains a field-symmetric mode that carries electromagnetic energy across the extent of the slit. A significant portion of the fields radiating from the slit exit propagates in free-space away from the metal surface (captured by the $D_3$ detector), and a lesser portion of the fields couple into confined left- and right-propagating modes on the metal surface (captured by the detectors $D_1$ and $D_2$). The wavelength of the confined mode on the metal surface is $\lambda_{SPP} = 480 \pm 10\text{nm}$, where the error corresponds to the observed variation of the SPP mode wavelength as a function of distance from the slit. An SPP coupling efficiency of $\simeq 0.20$ is measured for the slit immersed in free space. SPP coupling efficiencies of $\simeq 0.21$
and $\approx 0.25$ are measured, respectively, for the dielectric-filled slit immersed in free space and the slit immersed in dielectric (see Table 1).

Variations in the thickness of the dielectric layer on the metal film enable tuning of the SPP wavevector, $k_{SPP}$, and hence, the effective refractive index of the SPP mode, $n_{SPP} = k_{SPP}/k_0$. The dispersion curves for $n_{SPP}$ as a function of $\lambda_0$ and $d$ are determined by iteratively solving the complex eigenvalue equation for the wavevector $k_{SPP}$ of the mode sustained by an asymmetric, three-layer silver-glass-air waveguide, where the thickness of the glass layer is $d$. As shown in Fig. 4(a), $n_{SPP}$ increases asymptotically as $\lambda_0$ decreases from 1900 nm to 400 nm. For finite $d$, the $n_{SPP}$ dispersion curves are bound between the curves corresponding to $d = 0$ (air-silver interface) and $d \gg \lambda_0$ (glass-silver interface). As shown in Fig. 4(b), at a fixed $\lambda_0 = 500$ nm, $n_{SPP}$ as a function of $d$ can assume a continuum of values in the range $1.05 < n_{SPP} < 1.72$. The condition $n_{SPP} \approx \sqrt{\varepsilon_d} = 1.5$ is predicted to occur for a dielectric layer thickness $d \approx 75$ nm.

Figure 5 displays the instantaneous $|H_y|^2$ distributions for illumination of silver films with dielectric layer thicknesses of $d = 100$ nm and $d = 500$ nm. The slit width $w = 150$ nm is held constant. High-efficiency SPP coupling is evident for $d = 100$ nm; the presence of the $d = 100$ nm dielectric layer on the metal film yields negligible radiated intensity and relatively high SPP intensity. SPP coupling efficiency drops as the dielectric layer thickness increases to $d = 500$ nm; the $|H_y|^2$ distribution reveals an increase in the radiated intensity and a reduction in the SPP intensity relative to that for $d = 100$ nm.

Figure 6 displays the time-averaged radiated intensity $I_r$ and time-averaged SPP intensity $I_{SPP}$ as a function of $d$, along with the corresponding SPP-coupling efficiency, $\eta$. Appropri-
Fig. 6. (a) The time-averaged SPP intensity, $I_{SPP}$ (blue squares), and time-averaged radiated intensity, $I_r$ (red circles), and (b) the corresponding SPP coupling efficiency, $\eta$, as a function of $d$. The error bars describe the uncertainties in the measurement of $I_{SPP}$ and $I_r$ due to, respectively, the finite amount of $I_r$ captured by $D_1$ and $D_2$ and the finite amount of $I_{SPP}$ captured by $D_3$.

Fig. 7. SPP wavelength measured from the FDTD simulations (blue squares) and predicted from the mode solver (red line) as a function of dielectric layer thickness $d$. The dotted gray line indicates the value of $\lambda_i = \lambda_0 / \sqrt{\varepsilon_d}$. The error bars describe the uncertainty in the measurement of $\lambda_{SPP}$ from the FDTD simulations due to variation in $\lambda_{SPP}$ as a function of distance from the slit exit.

Ately selecting the dielectric layer thickness can yield both enhanced SPP coupling and reduced radiation from the slit. For values of $d$ in the range $50\text{ nm} < d < 150\text{ nm}$, $I_{SPP}$ is near-maximum and $I_r$ is near-minimum, yielding an SPP-coupling efficiency $\approx 0.77$. For values of $d > 150\text{ nm}$, the efficiency curve drops and flattens. In the limits where $d \to 0\text{ nm}$ and $d \to 700\text{ nm}$, the SPP-coupling efficiencies approach $\eta \to 0.20$ and $\eta \to 0.31$, respectively.

The layer thickness corresponding to high coupling efficiency approximately coincides with the layer thickness where the SPP wavelength, $\lambda_{SPP}$, matches the wavelength of light at the slit exit $\lambda_i = \lambda_0 / \sqrt{\varepsilon_d}$. Figure 7 plots the SPP wavelength as a function of the dielectric layer thickness $d$. The SPP wavelength has been obtained by two methods: direct measurement from the FDTD-calculated $|H_y^2|$ distributions and calculation via the SPP modal solutions of the
Fig. 8. Image of the FDTD-calculated instantaneous $|H_y|^2$ distribution for a slit illuminated by a quasi-plane-wave of wavelength $\lambda_0 = 500$nm when the slit width is (a) 150nm and (b) 300nm. The dielectric layer thickness $d = 100$nm is held constant. The simulation geometry is depicted by the above graphic.

asymmetric silver-glass-air waveguide. There is a good match between the SPP wavelength values obtained by the FDTD simulations and the modal solutions. As $d$ increases from 0nm to 500nm, the SPP wavelength reduces from 480nm to 300nm. At the layer thickness $d \approx 100$nm yielding maximum SPP coupling efficiency, $k_{SPP}$ nearly matches $k_i$, which has been assumed to be $\sqrt{\varepsilon}k_0$ (although this is not generally true, as the modes at the exit of the slit assume a distribution of wavevector magnitudes). The correlation between the high coupling efficiency and wavelength similarity between the SPP mode and the plane-wave mode in the dielectric suggest that phase-matched coupling is the primary culprit in the efficiency enhancement.

Changing the slit width affects the distribution of the modes at the exit of the slit, which in turn affects the SPP coupling efficiency. Figure 8 displays the instantaneous $|H_y|^2$ distributions for illumination of silver films with slit widths of $w = 150$nm and $w = 300$nm. The dielectric layer thickness $d = 100$nm is held constant. The narrower slit shows weaker overall transmission through the slit, with the majority of the transmitted field coupled into the bounded SPP modes on the metal surface at the exit side of the slit. The wider slit exhibits greater overall transmission, with a significant portion of the transmission radiating from the metal surface. As $w$ increases, a greater percentage of the modes at the slit exit are propagating modes that radiate away from the metal surface. In the limit where the slit width is very large ($w >> \lambda_0$), a ray picture can be used where the majority of the incident light rays propagate directly through the slit and away from the slit exit.

Increasing the slit width generally reduces the efficiency of SPP coupling from the slit structure. The influence of the slit width on $I_{SPP}$, $I_r$, and $\eta$ is plotted in Fig. 9. As $w$ increases from 50nm to 300nm, $I_r$ increases monotonically, while $I_{SPP}$ peaks at $w = 250$nm and then
Fig. 9. a) The time-averaged SPP intensity, $I_{SPP}$ (blue squares), and time-averaged radiated intensity, $I_r$ (red circles), and (b) the corresponding SPP coupling efficiency, $\eta$, as a function of $w$. The error bars describe the uncertainties in the measurement of $I_{SPP}$ and $I_r$ due, respectively, the finite amount of $I_r$ captured by $D_1$ and $D_2$ and the finite amount of $I_{SPP}$ captured by $D_3$.

decreases at $w = 300\text{nm}$. The corresponding SPP coupling efficiency monotonically decreases from $\simeq 0.83$ to $\simeq 0.18$ as the slit width increases from 50nm to 300nm.

To investigate the wavelength-sensitivity of the coupling structure, the electromagnetic response of a coupling structure with slit width $w = 200\text{nm}$ and dielectric layer thickness $d = 100\text{nm}$ is studied over free-space wavelengths ranging from 400nm to 700nm, in increments of 100nm. SPP coupling efficiencies of 0.66, 0.67, 0.66, and 0.65 are observed at wavelengths of 400nm, 500nm, 600nm, and 700nm, respectively. The coupling efficiency is largely insensitive to wavelength because the condition $k_{SPP} \simeq k_i$ is achieved via near-field perturbation of the SPP mode using a $d \ll \lambda_0$ layer. That is, the dielectric layer shifts the $k_{SPP}$ wavevector commensurately throughout the visible frequency range.

6. Summary

In conclusion, we have proposed a method for enhancing the efficiency of slit-coupling from a free-space plane-wave mode into a SPP mode on a metal film. The key element of the coupling scheme involves an ultra-thin dielectric layer placed on the exit side of the metal film. Varying the thickness of the dielectric layer enables tuning of the SPP wavevector. When the SPP wavevector is matched with the wavevector magnitude of the modes exiting the slit, coupling efficiencies $\simeq 0.80$ can be achieved, $\simeq$ 4-times enhancement relative to the case without the dielectric layer. In addition to enhancing SPP coupling efficiency, the dielectric layer has the added benefit of passivation and protection of the SPP-sustaining metal surface. The results will find utility in the growing field of plasmonics and help pave the way towards real-world implementation of SPP devices.

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